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APPLICATION NO.	FILING D	DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
10/087,556	03/01/2	002	Katsumi Yamaguchi	TI-31471	2191		
23494	7590	11/28/2003		EXAM	EXAMINER		
TEXAS INSTRUMENTS INCORPORATED P O BOX 655474, M/S 3999					, JUNGHWA M		
DALLAS, T	•	7		ART UNIT	ART UNIT PAPER NUMBER		
				2811			
				DATE MAILED: 11/28/200	3		

Please find below and/or attached an Office communication concerning this application or proceeding.

• 41	Application No.	Applicant(s)						
,	10/087,556	YAMAGUCHI ET	YAMAGUCHI ET AL.					
Office Action Summary	Examiner	Art Unit						
	Junghwa M. Im	2811	AW					
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet	with the correspondence ac	ldress					
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep If NO period for reply is specified above, the maximum statutory period Failure to reply within the set or extended period for reply will, by statut - Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b). Status	136(a). In no event, however, may a sly within the statutory minimum of the will apply and will expire SIX (6) MC e, cause the application to become a	a reply be timely filed nirty (30) days will be considered timel DNTHS from the mailing date of this c ABANDONED (35 U.S.C. § 133).						
1) Responsive to communication(s) filed on 22 S	September 2003.							
2a) ☐ This action is FINAL . 2b) ☑ This	This action is FINAL . 2b)⊠ This action is non-final.							
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.								
Disposition of Claims								
4) ☐ Claim(s) is/are pending in the application 4a) Of the above claim(s) is/are withdra 5) ☐ Claim(s) is/are allowed. 6) ☒ Claim(s) 1-6 and 9-22 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or	wn from consideration.							
Application Papers								
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct	cepted or b) objected to drawing(s) be held in abeyont on its required if the drawing	ance. See 37 CFR 1.85(a). g(s) is objected to. See 37 C						
11) The oath or declaration is objected to by the E Priority under 35 U.S.C. §§ 119 and 120	xaminer. Note the attach	ed Office Action of form P	10-152.					
12) Acknowledgment is made of a claim for foreig a) All b) Some * c) None of: 1. Certified copies of the priority documen 2. Certified copies of the priority documen 3. Copies of the certified copies of the priority documen application from the International Burea * See the attached detailed Office action for a list 13) Acknowledgment is made of a claim for domest since a specific reference was included in the fir 37 CFR 1.78. a) The translation of the foreign language priority acknowledgment is made of a claim for domest reference was included in the first sentence of the company of the foreign language priority.	ts have been received. ts have been received in brity documents have been tu (PCT Rule 17.2(a)). t of the certified copies not tic priority under 35 U.S.C rst sentence of the specific tic priority under 35 U.S.C tic priority under 35 U.S.C	Application No In received in this National of received. C. § 119(e) (to a provisional ication or in an Application been received. C. §§ 120 and/or 121 since	l application) Data Sheet. a specific					
Attachment(s)	. □	. O	/-A					
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 	5) D Notice of	r Summary (PTO-413) Paper No(f Informal Patent Application (PTO						

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DETAILED ACTION

In view of the appeal brief filed on September 22, 2003, PROSECUTION IS HEREBY REOPENED. A new ground rejection is set forth below.

Prosecution is being reopened to reduce issues for appeal and to address the limitation of Claim 2 based on the Kanda et al. reference.

To avoid abandonment of the application, appellant must exercise one of the following two options:

- (1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37 CFR 1.113 (if this Office action is final); or,
 - (2) request reinstatement of the appeal.

If reinstatement of the appeal is requested, such request must be accompanied by a supplemental appeal brief, but no new amendments, affidavits (37 CFR 1.130, 1.131 or 1.132) or other evidence are permitted. See 37 CFR 1.193(b)(2).

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.

Claims 1, 3-6, 9, 11, 12 and 18-22 are rejected under 35 U.S.C. 102(e) as being anticipated by Kanda et al. (US 6,153,938), hereafter Kanda.

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Regarding claims 1 and 3-6, Fig. 1C of Kanda shows a semiconductor device comprising: a contact pad (col. 6, lines 15-18) on a semiconductor substrate 1, a conductive gold bump 2 (col. 5, line 43) on the contact pad, the bump comprising a coaxially-aligned circular bodies having different cross-sectional dimensions, said bodies at the top of said stack having smaller cross-sectional dimensions.

Regarding claim 9, Fig. 1C of Kanda shows bodies at the top of said stack have a smaller height than lower bodies in said stack.

Regarding claim 11, Fig. 1C of Kanda shows the semiconductor device further comprising a passivation film 9 around said contact pad.

Regarding claim 12, Fig. 1C of Kanda shows the sides of the contact pad is on an insulating film 9 on said semiconductor substrate.

Regarding claim 18, Fig. 1C of Kanda shows a semiconductor device, comprising:

a semiconductor substrate 1, a contact pad (col. 6, lines 15-18) on said semiconductor substrate; a first bump 2 on said contact pad; a smaller second bump on said first bump, said second bump coaxially aligned with said first bump and having a substantially flat peak plane; a printed circuit board 6, wherein said semiconductor substrate is mounted over said printed circuit board such that said contact pad and said first and second bumps are aligned with a conductive film 7 on said printed circuit board.

Limitations for claims 19-22 have been discussed above in claim 11, 9, 3 and 4 respectively.

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Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 2 is rejected under 35 U.S.C. 103(a) as being unpatentable over Kanda in view of Murakami (US 5,874,780).

Regarding claim 2, Kanda shows substantially the entire claimed structure except "the uppermost body in said stacked has a flat peak plane." Fig. 7C of Murakami shows the uppermost body in the stack has a flat peak plane. It would have been obvious to one of ordinary skill in the art at the time of the invention to incorporate the teaching of Murakami to of Kanda's bump structure in order to form a flat top surface of the uppermost body to improve the contact between the chip and the corresponding substrate.

Claims 10, 12 and 13-17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kanda in view of Lin (US 6,426,556).

Regarding claims 10 and 12, Fig. 1C of Kanda shows substantially the entire claimed device except a barrier layer and an insulation layer. However, Fig. 15 of Lin shows a gold bump (35) formed on a contact pad (24) on an insulating film (29) on a substrate (10) with a barrier formation (33, 34) between the contact pad and the bump. See the respective portions of the specification such as col. 3, lines 11-28.

It would have been obvious to one of ordinary skill in the art at the time of the invention

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to incorporate the teaching of Lin to the device of Kanda in order to form an barrier layer between a contact pad and a bump since a barrier layer between a contact pad and a bump serves to prevent diffusion of solder material into underlying layers. In addition, it would have been obvious to one of ordinary skill in the art at the time of the invention to add an insulating layer on a substrate of Kanda's device with Lin's teaching in order to alleviate a noise interference through the substrate to a conductive pad.

Regarding claim 13, Fig. 1C of shows Kanda a semiconductor device, comprising: a contact pad (col. 6, lines 15-18) on a semiconductor substrate (1); a first bump (a larger one of 2) having a first cross-sectional dimension; a second bump on and coaxially aligned with said first bump, said second bump having a cross-sectional dimension smaller than said first cross-sectional dimension. However, Fig. 15 of Lin shows a gold bump (35) formation on a contact pad (24) with a barrier layer (33, 34) in between while a contact pad is formed on a dielectric layer (29) on a substrate (10).

Motivations for a barrier layer and an insulating layer have been discussed above.

Regarding claims 14-17, Fig. 1C of Kanda shows the semiconductor device further comprising a passivation film (9) around said contact pad, and two circular gold bumps(col. 5, line 43) while the height of the first bump is greater than the height of the second bump.

Response to Arguments

In view of the appeal brief filed on September 22, 2003, PROSECUTION IS HEREBY REOPENED. A new ground of rejection is set forth below.

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The rejection over Murakami is withdrawn and a new rejection regarding claim 2 is made

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over Murakami and Kanda.

To avoid abandonment of the application, appellant must exercise one of the following

two options:

(1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37

CFR 1.113 (if this Office action is final); or,

(2) request reinstatement of the appeal.

If reinstatement of the appeal is requested, such request must be accompanied by a

supplemental appeal brief, but no new amendments, affidavits (37 CFR 1.130, 1.131 or 1.132) or

other evidence are permitted. See 37 CFR 1.193(b)(2).

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Junghwa M. Im whose telephone number is (703) 305-3998. The

examiner can normally be reached on MON.-FRI. 8:30AM-5:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Eddie C Lee can be reached on (703) 308-1690. The fax phone number for the

organization where this application or proceeding is assigned is (703) 872-9318.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (703) 308-0956.

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imi

November 18, 2003

EDDIE LEE

SUPERVISORY PATENT EXAMINER

TECHNOLOGY CENTER 2800